AMENDMENT TRANSMITTAL LETTER (Large Entity) Applicant(s): Cheng et al.						Docket No. 2000-0484B/n1085-90119				
Application No.	Filing Date	Examiner		Customer No	o. (Group Art Unit	Confirmation No.			
10/649,472	8/27/03	Chen, Kin Chan		08933		1765	5371			
IDVENTION: NOVEL CHEMICAL-MECHANICAL POLISHING CMP PROCESS FOR SHALLOW TRENCH ISOLATION AUG 12 2005										
COMMISSIONER FOR PATENTS: Transmitted herewith is an amendment in the above-identified application. The fee has been calculated and is transmitted as shown below.										
		CLAIMS AS AM	ENDED)						
·	CLAIMS REMAINING AFTER AMENDMENT	HIGHEST # PREV. PAID FOR		ER EXTRA PRESENT		RATE	ADDITIONAL FEE			
TOTAL CLAIMS	15 -	32 =		0 >	x	\$50.00	\$0.00			
INDEP. CLAIMS	2 -	3 =		0 >	X	\$200.00	\$0.00			
Multiple Dependen	t Claims (check if appl	licable)	<u> </u>				\$0.00			
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT \$0.00										
 No additional fee is required for amendment. □ Please charge Deposit Account No. in the amount of □ A check in the amount of to cover the filing fee is enclosed. ☑ The Director is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account 50-2061 ☑ Any additional filing fees required under 37 C.F.R. 1.16. ☑ Any patent application processing fees under 37 CFR 1.17. □ Payment by credit card. Form PTO-2038. WARNING: Information on this form may become public. Credit card information should not be included on this form. Provide credit card information and authorization on PTO-2038. 										
Paul A. Schwarz										
Registration No. 37,577 Duane Morris LLP P.O.Box 5203 Princeton, New Jersey 08543 Tel.: 609-631-2446 Fax: 609-631-2401						s correspondence is being deposited with all Service with sufficient postage as first addressed to "Commissioner for Patents, a, VA 22313-1450" [37 CFR 1.8(a)] on				

CC:

Melody Dye

Typed or Printed Name of Person Mailing Correspondence

CERTIFICATE OF Applicant(s): Cheng e	Docket No. 2000-0484B/N1085-90119			
Application No. 10/649,472	Filing Date 8/27/03	Examiner Chen, Kin Chan	Customer No. 08933	Group Art Unit 1765
Invention: NOVEL C. ISOLATIO		CAL POLISHING CMP PROCESS FOR	R SHALLOW TR	RENCH
AUG 1 2 2005	と、世界			
I hereby certify that t	his <u>AMENDMENT</u>	(Identify type of correspondence)		
addressed to "Comm	nissioner for Patents, P.O. August 10, 2005 (Date)	Stal Service with sufficient postage as D. Box 1450, Alexandria, VA 22313-14 — . Melody (Typed or Printed Name of Person (Signature of Person Main	450" [37 CFR 1.8	8(a)] on
	Note: Each pa	per must have its own certificate of mailing.		
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Alis 12 2005 B AN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Patent Application of:

Cheng et al.

Group Art Unit: 1765

Application No.: 10/649,472

Examiner: Chen, Kin Chan

Filing Date: August 27, 2003

Docket No.: 2000-0484B/N1085-90119

For: Novel Chemical-Mechanical Polishing:

CMP Process for Shallow Trench Isolation:

Date: August 10, 2005

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT

Sir:

This paper is responsive to the Office Action dated May 10, 2005. Kindly enter the following amendments:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks begin on page 7 of this paper.